

New theory on electron-neutral sticking reactions

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mechanism





mechanism



electron capture theory

electron = quantum species

generally only s-waves important

Vogt-Wannier capture theory

(vs. resonance theory)

Klots-Hotop-Fabrikant formulae better

(analytical and accurate):

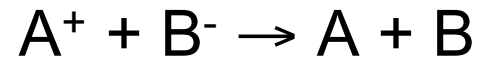
J. Troe, T. M. Miller, A. A. Viggiano

J. Chem. Phys. **127**, 244303, 244304 (2007)

E. I. Dashevskaya, I. Litvin, E. E. Nikitin, J. Troe

Phys. Chem. Chem. Phys. **10**, 1270 (2008)

Ion-ion mutual neutralization



Landau-Zener-type curve crossing

splitting-transition probability

Olson-Grice-Herschbach-Smirnov

multidimensional

energy redistribution

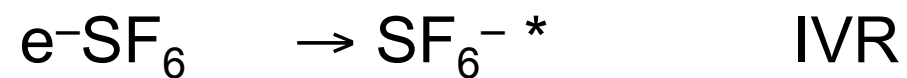
J. C. Bopp, T. M. Miller, A. A. Viggiano

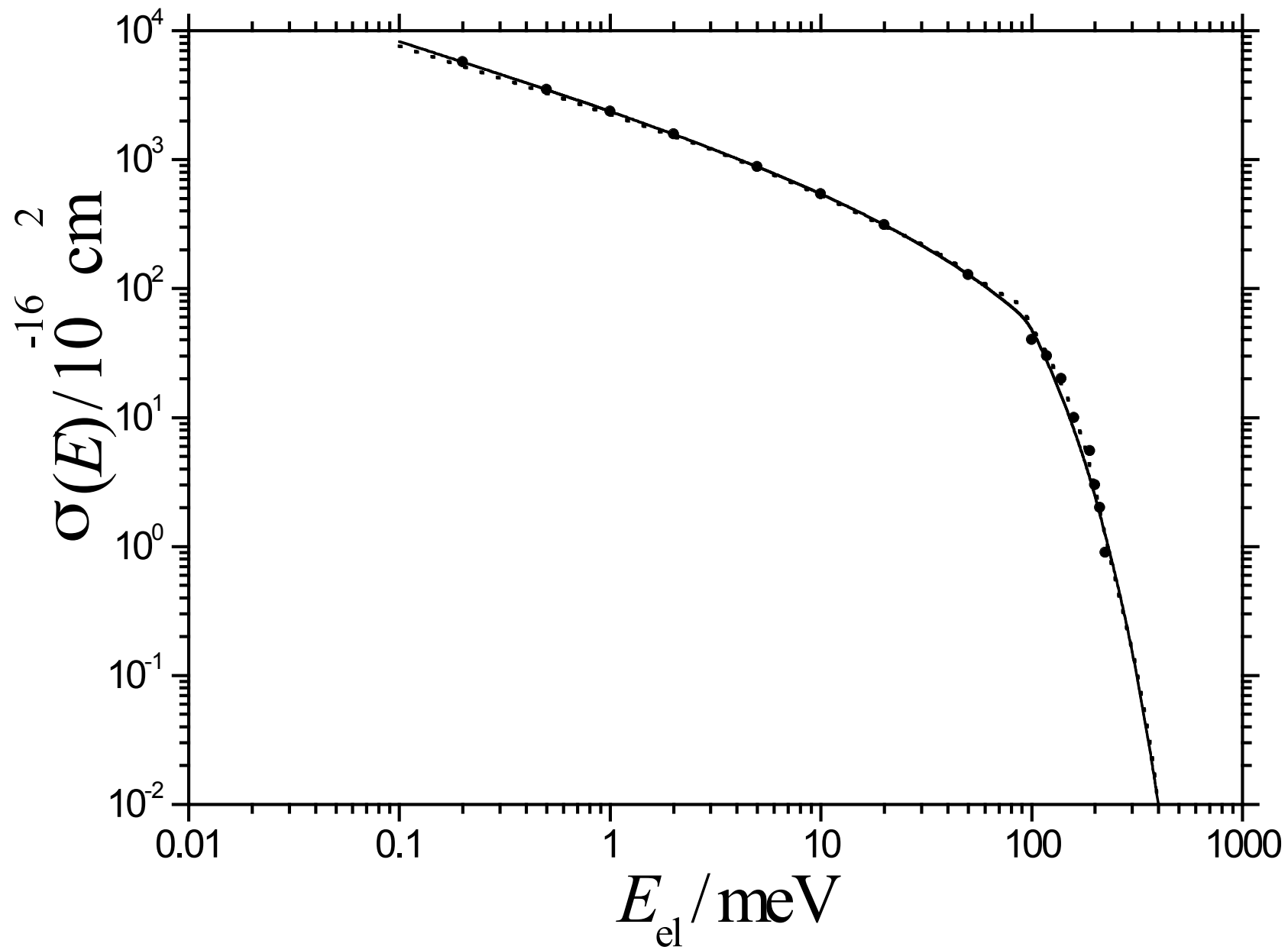
J. Chem. Phys. **129**, 074308 (2008)

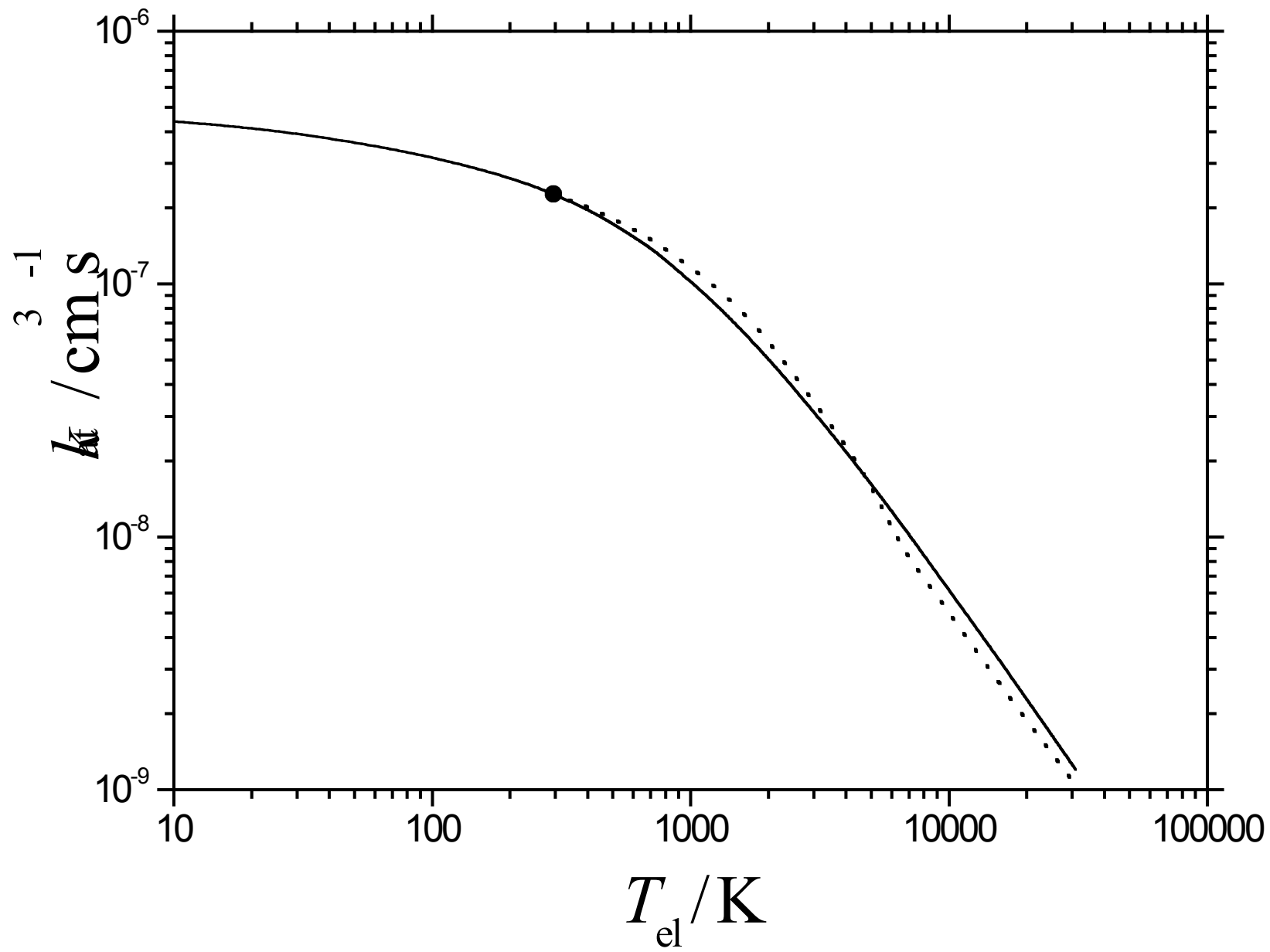
Quantum effects

- (i) quantization of orbital angular momentum of relative motion
(s-, p-, d-, ... mK - μ K)
- (ii) quantization of rotational angular momentum ($kT \approx B =$ rotational constant of dipole, hydrides 1 – 10 K, non-hydrides < 1 K)
- (iii) open electronic shells: coupling of rotational and electronic angular momentum (10 – 100 K)
- (iv) quantization of vibrations (high T, separable)
- (v) classical range
(Su & Chesnavich, Troe, Maergoiz, Nikitin, Troe & Ushakov)

Attachment mechanism







$$\sigma(E_{el}, 300 \text{ K}) \rightarrow k_{attach} (300 \text{ K})$$

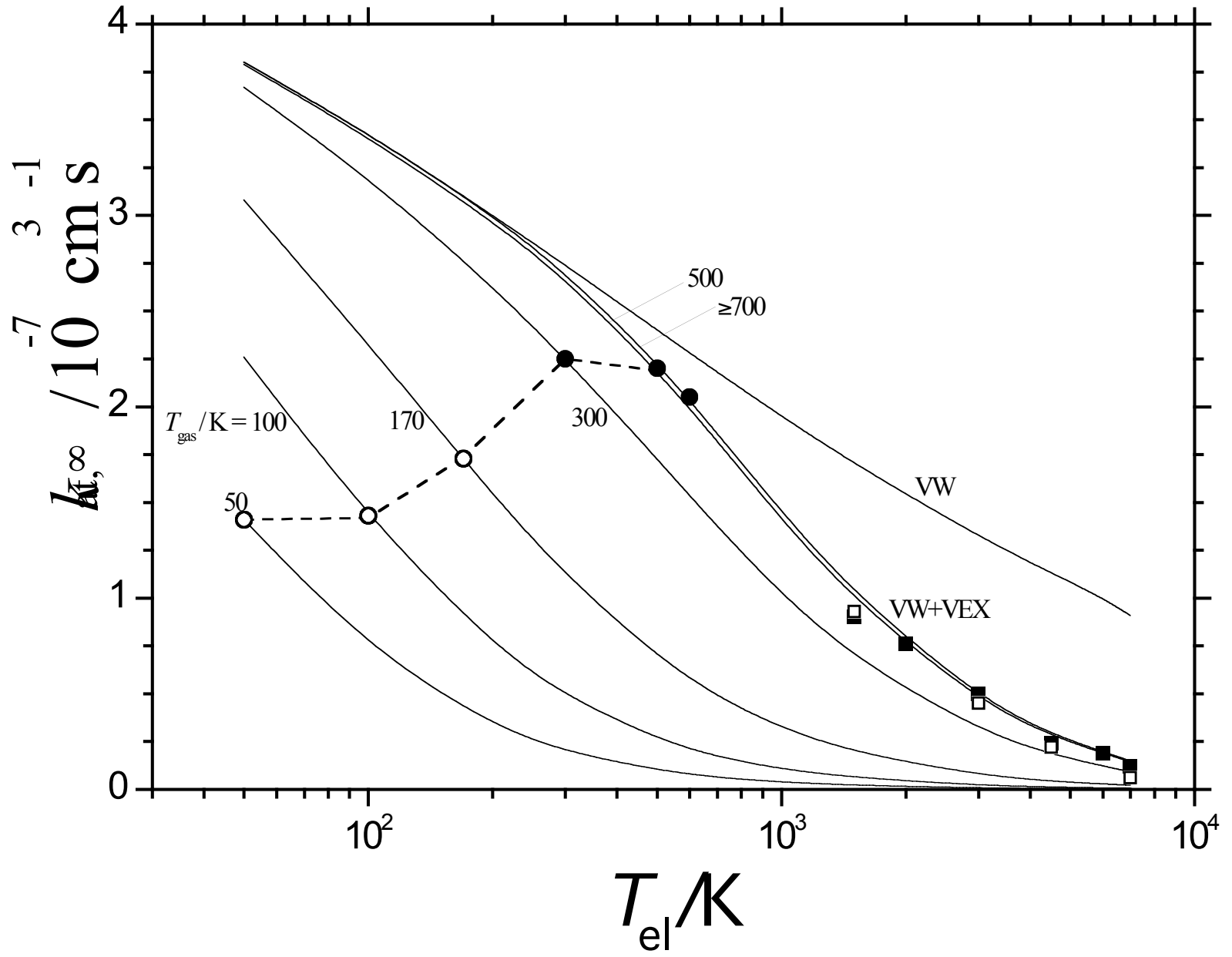
$k_{attach} (T_{gas})$ should decrease with T_{gas} but it does not do that

$$\Rightarrow k_{attach}(T_{el}, T_{gas})$$

WHY?

IVR accelerates with increasing T_{gas}

IVR slows down with increasing T_{el}



Fate of $\text{SF}_6^-^*$?

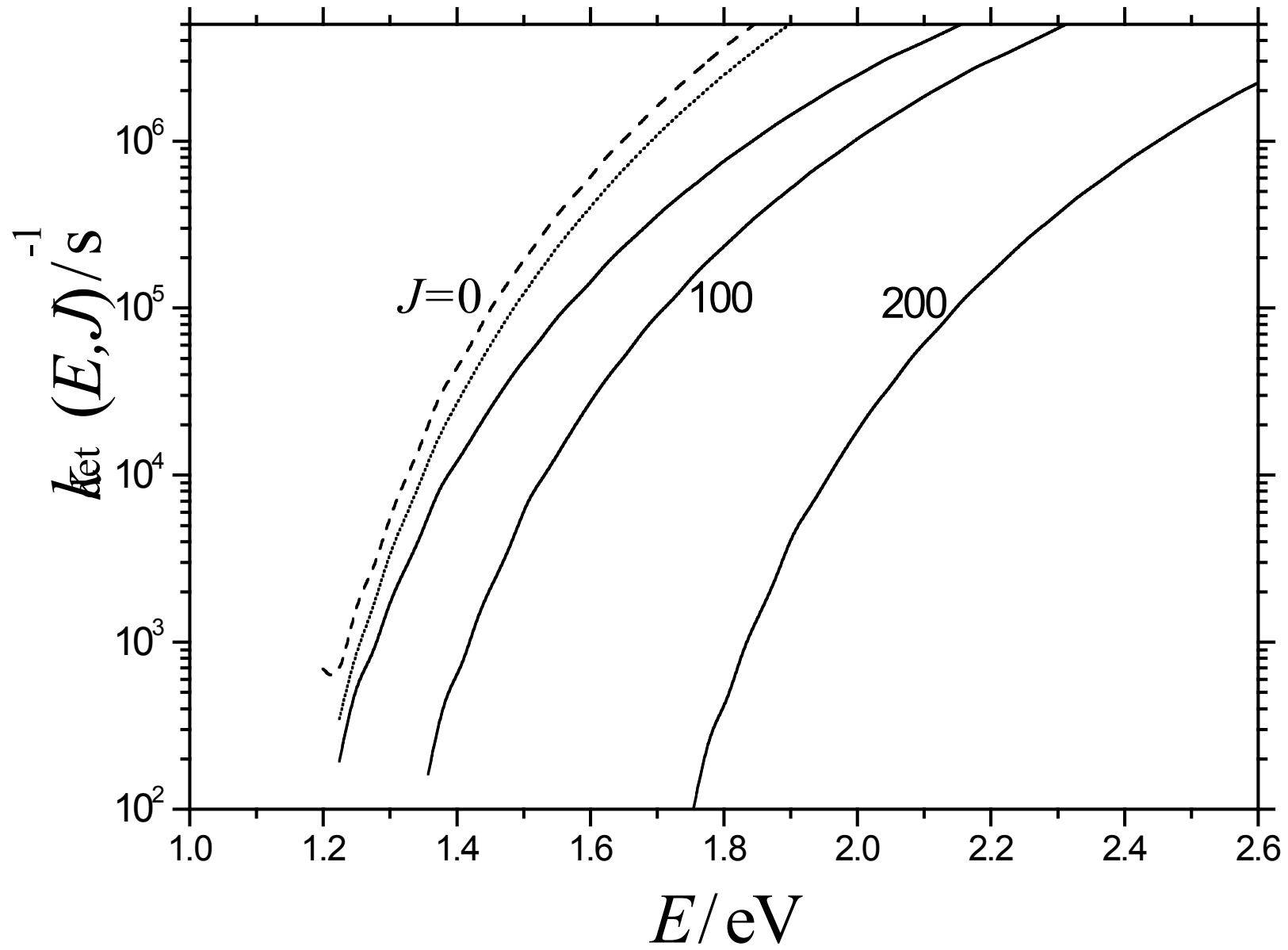
detection before decay

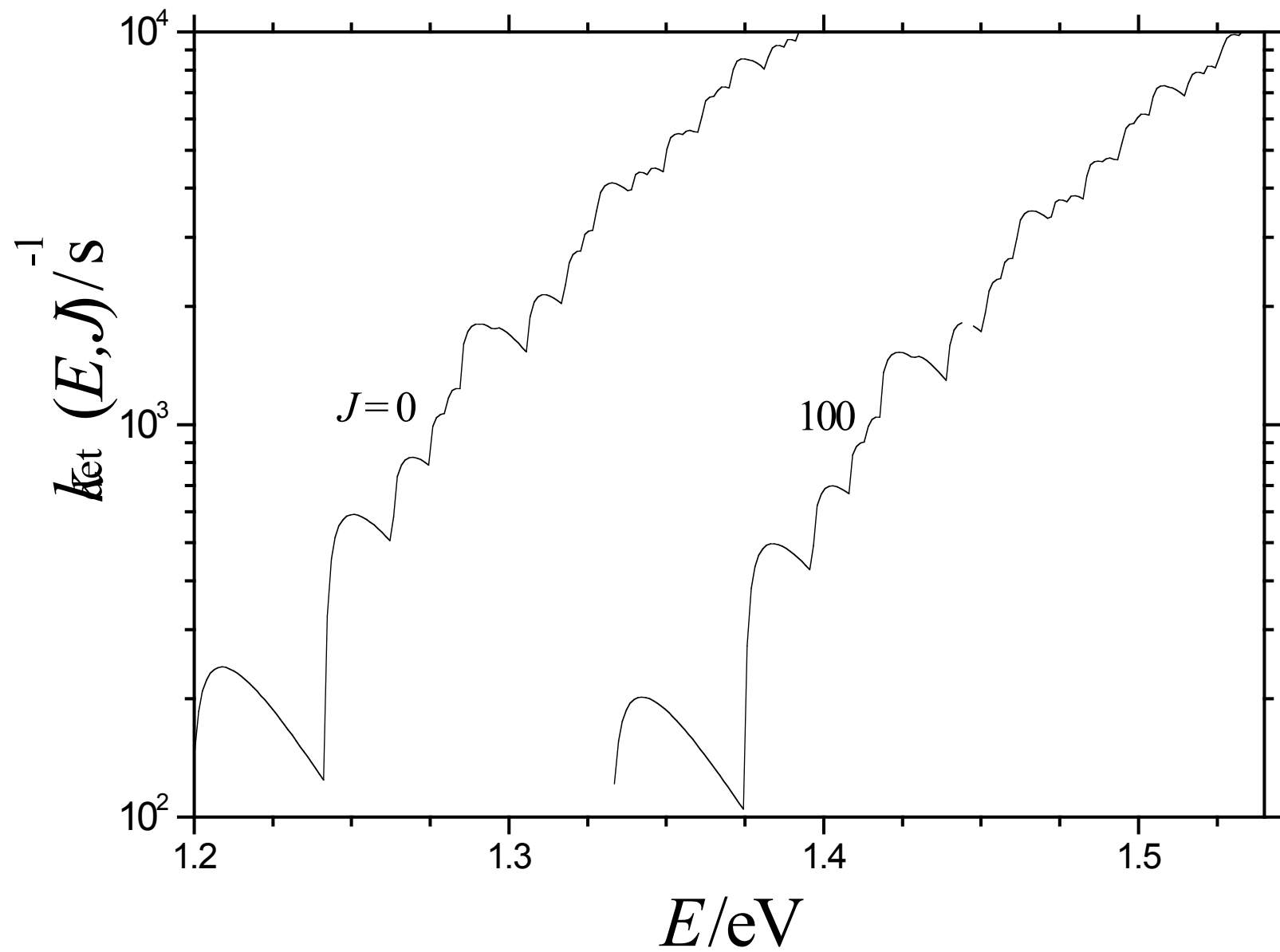
autodetachment: lifetime?

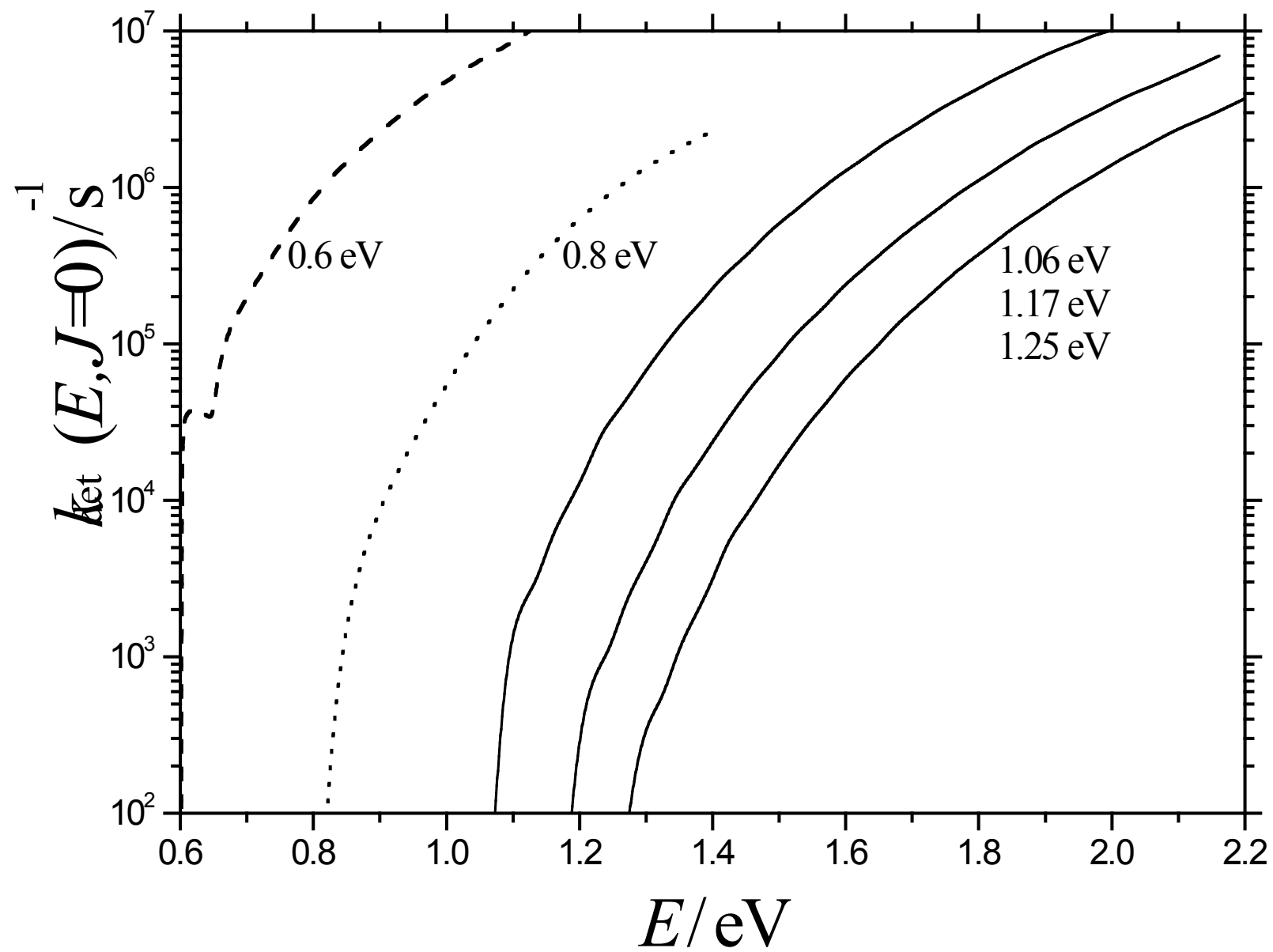
radiative stabilization?

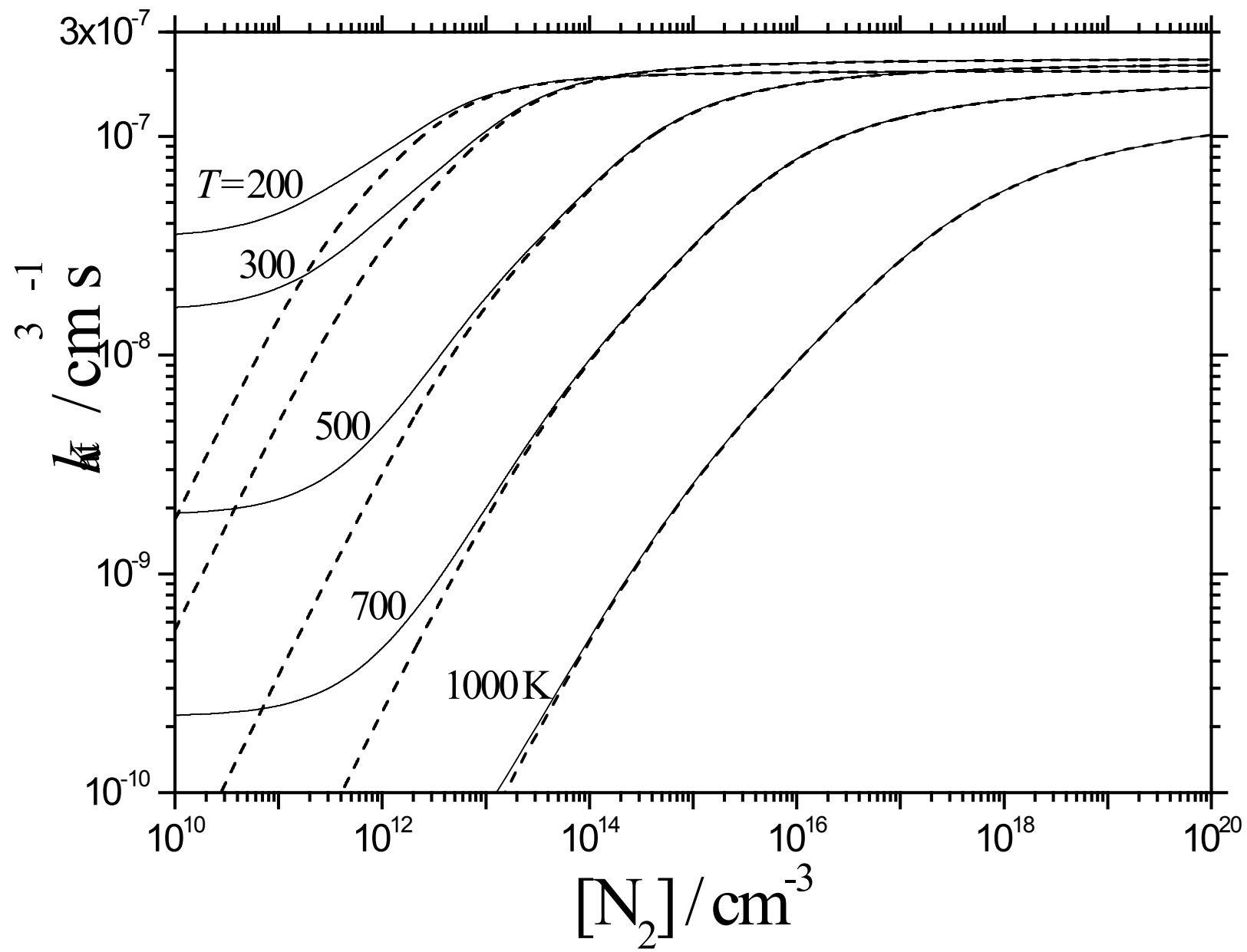
Kinetic modelling:

$$\sigma_{attach}(E_{el}, E_{vib}) \Leftrightarrow k_{detach}(E_{total}, T_{gas})$$

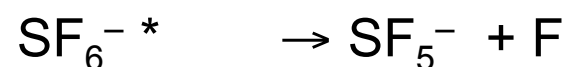
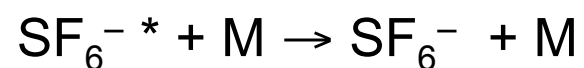




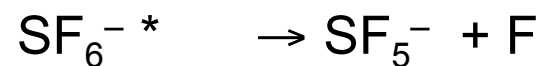
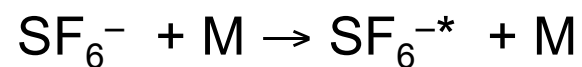




Dissociative attachment

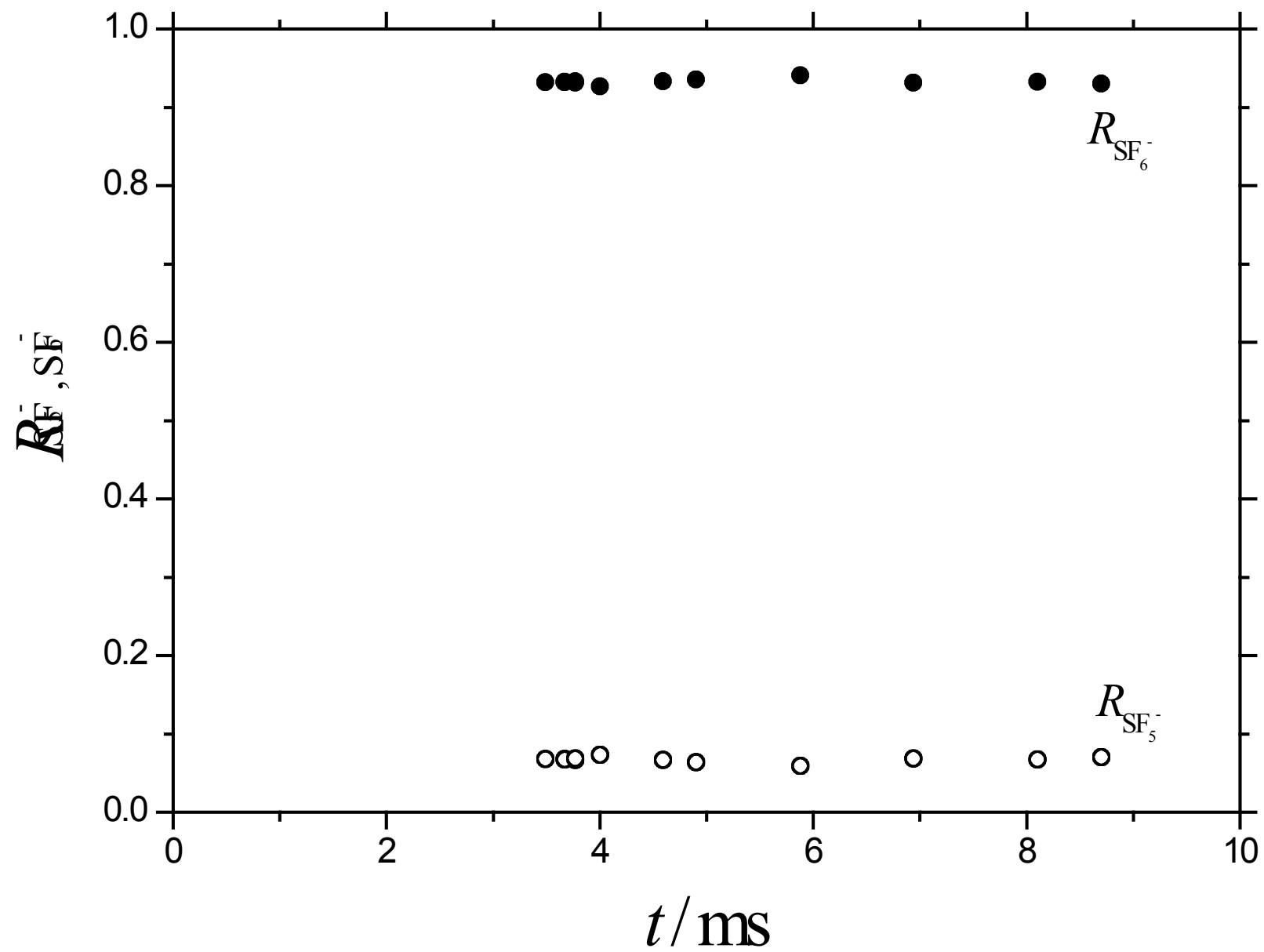


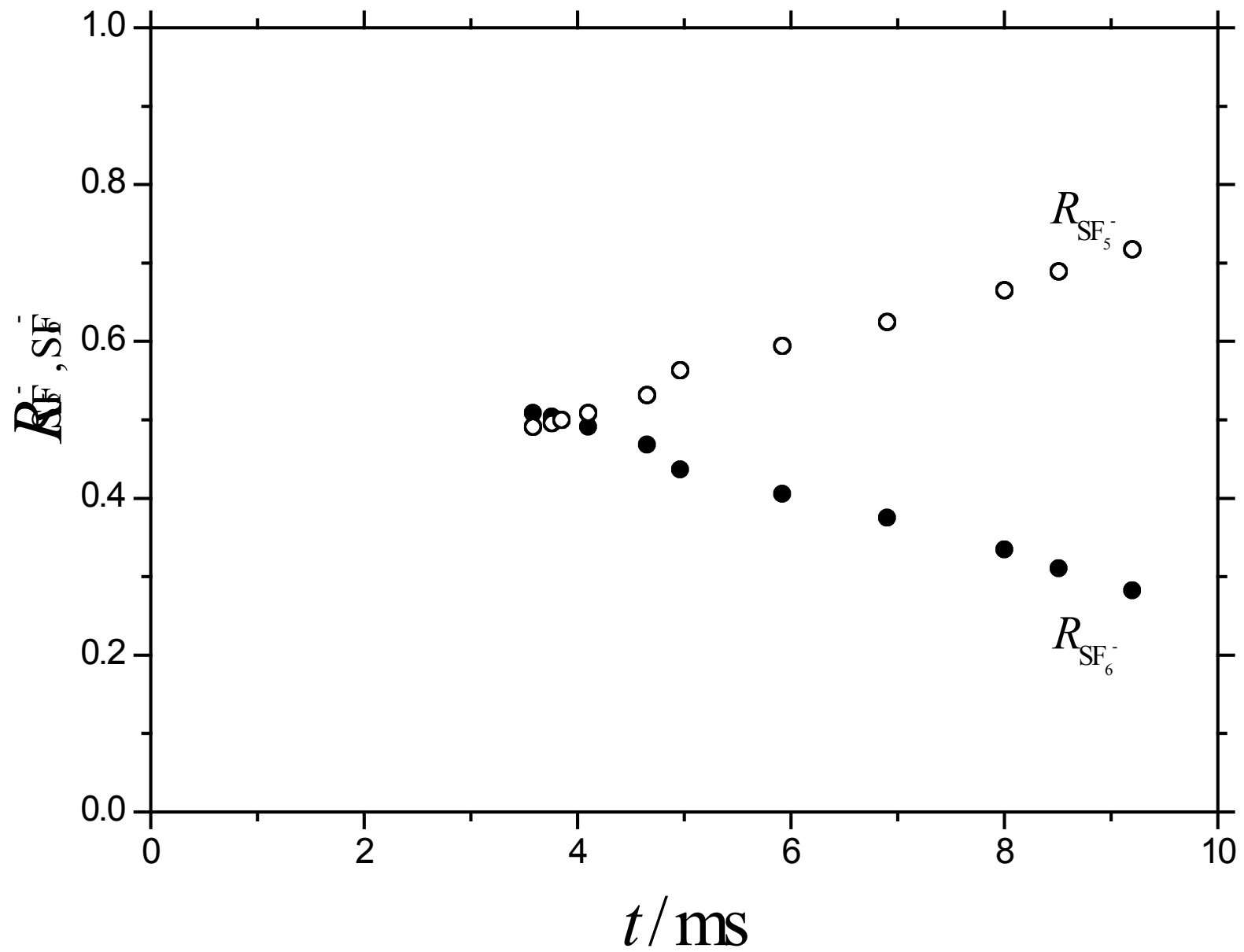
chemical activation system (fast)

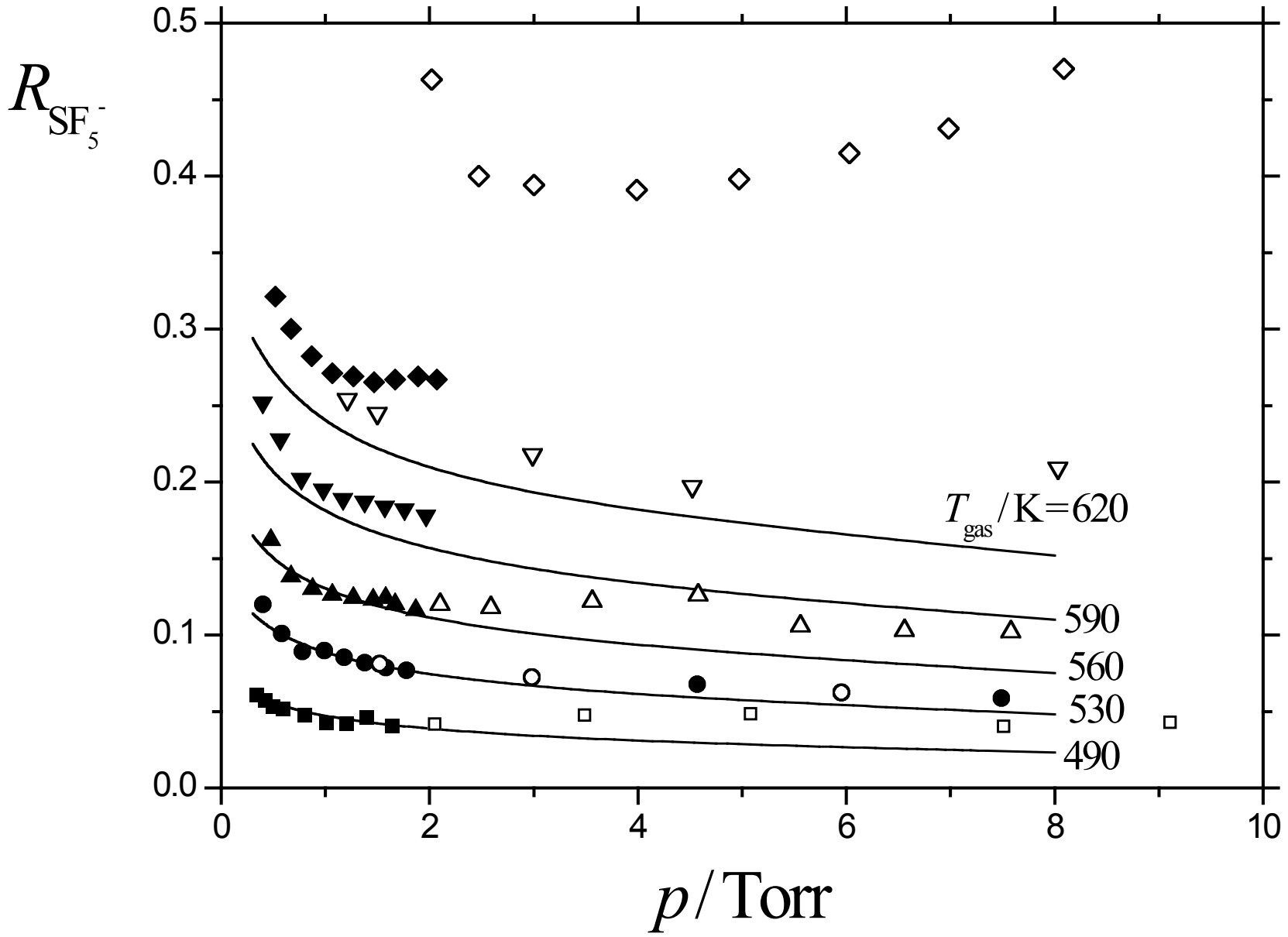


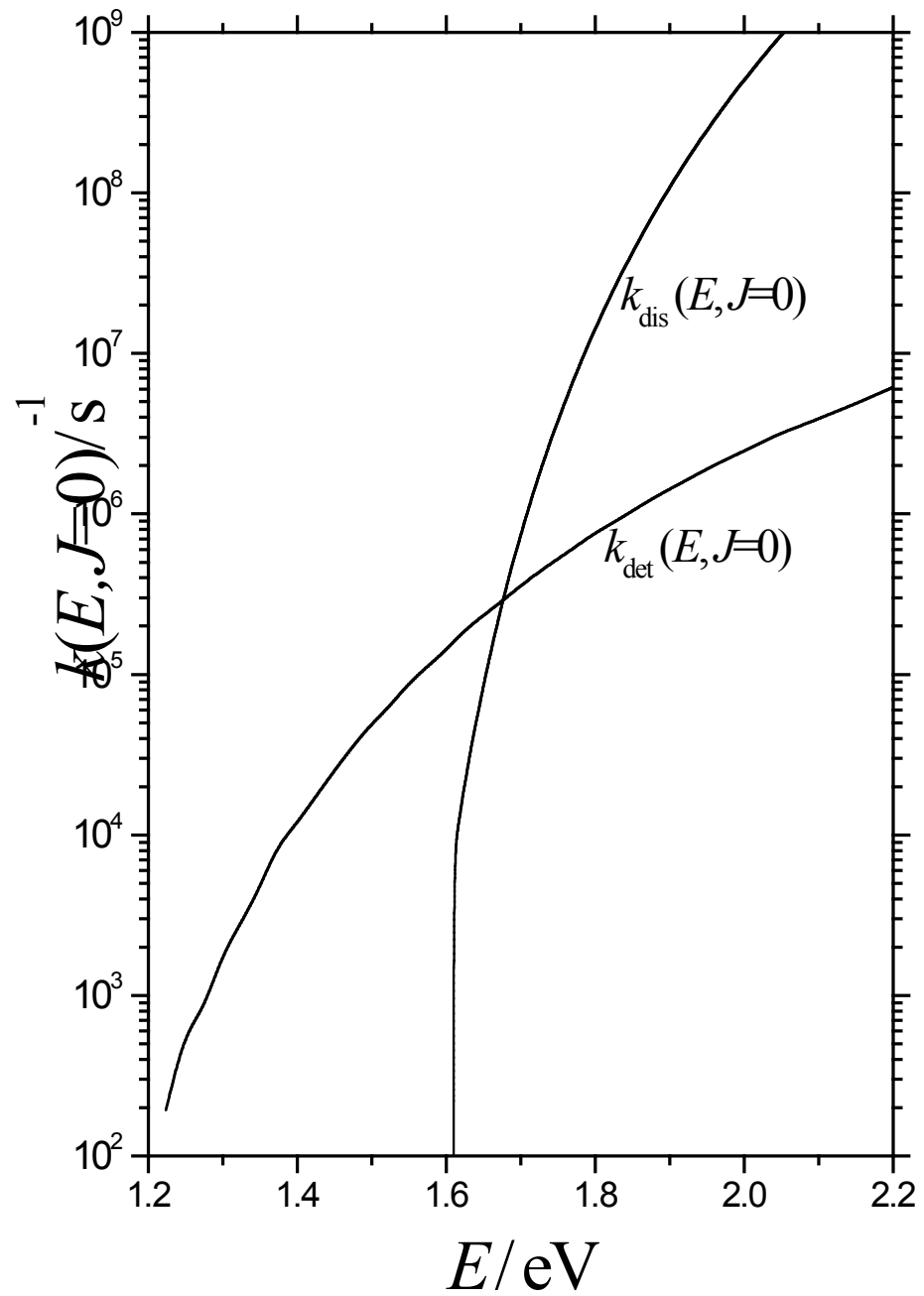
thermal dissociation (slow)

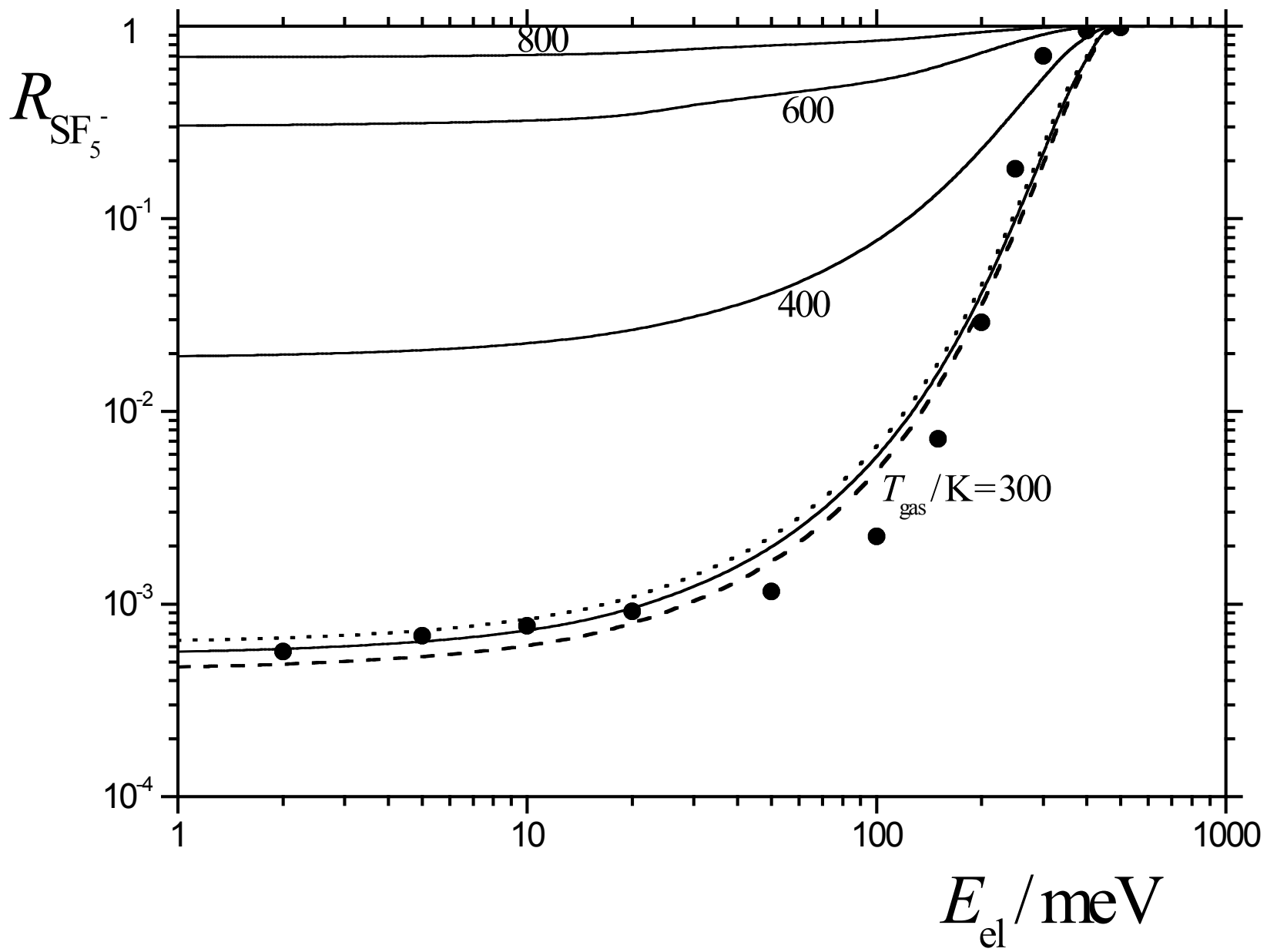
FALP studies at AFRL

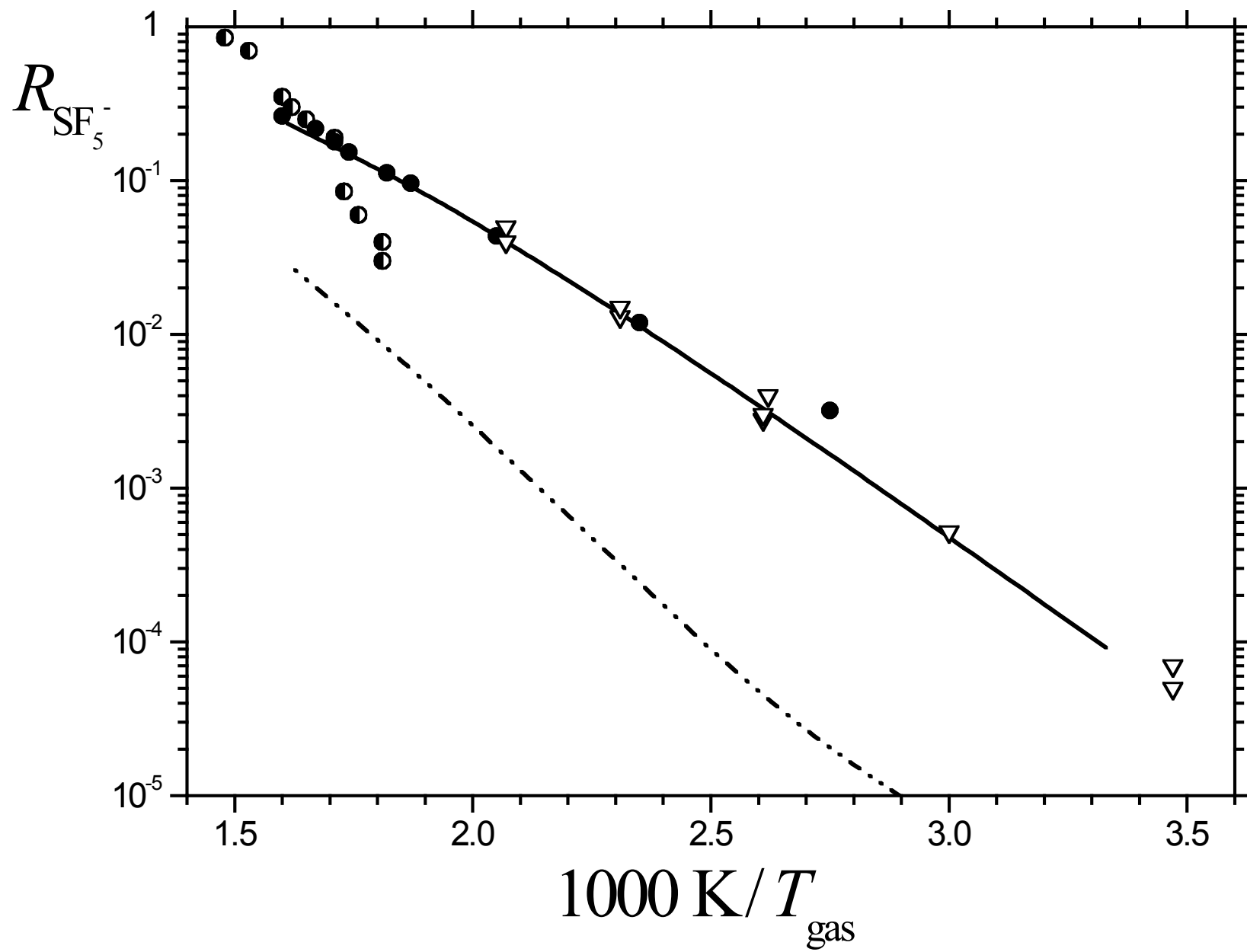


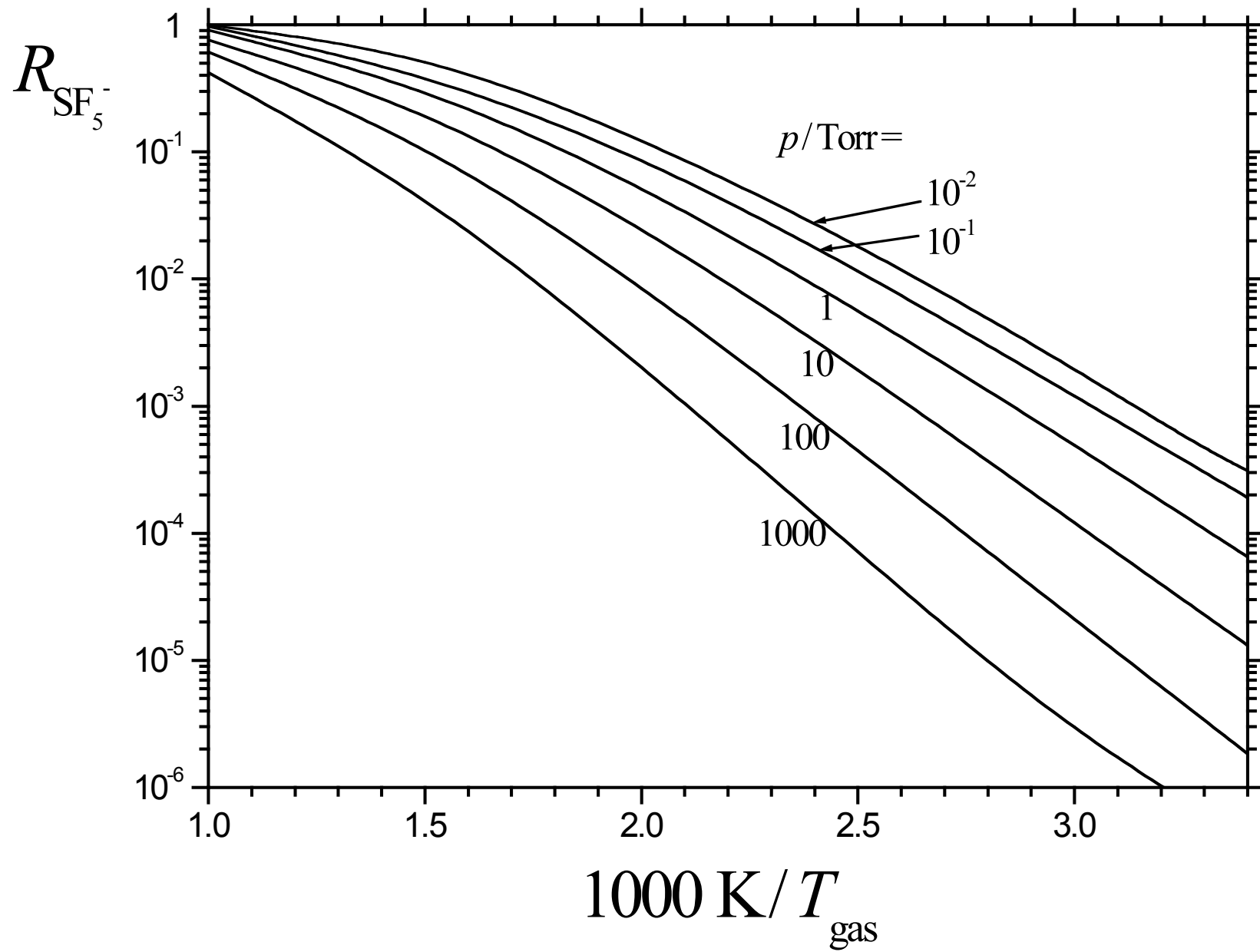


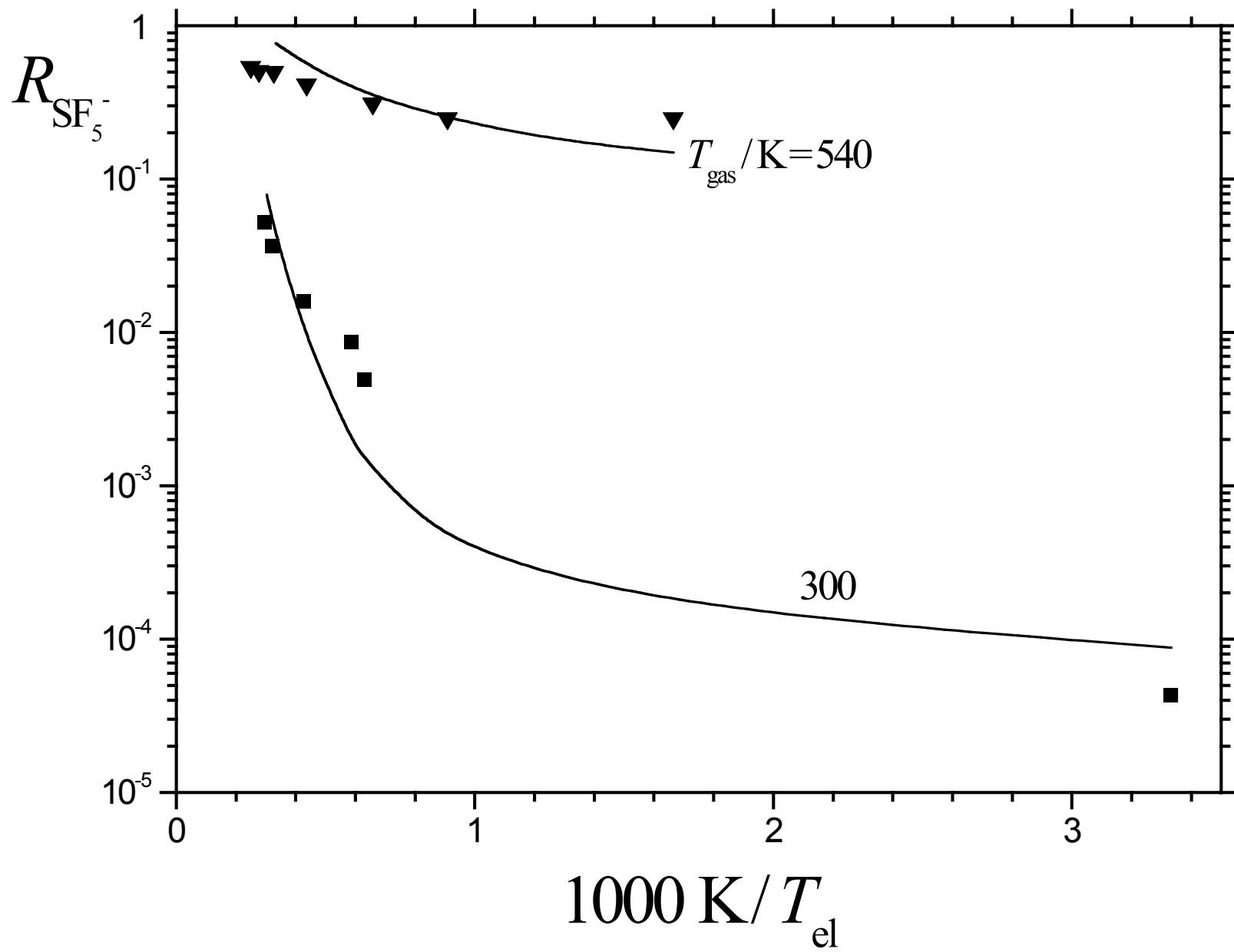


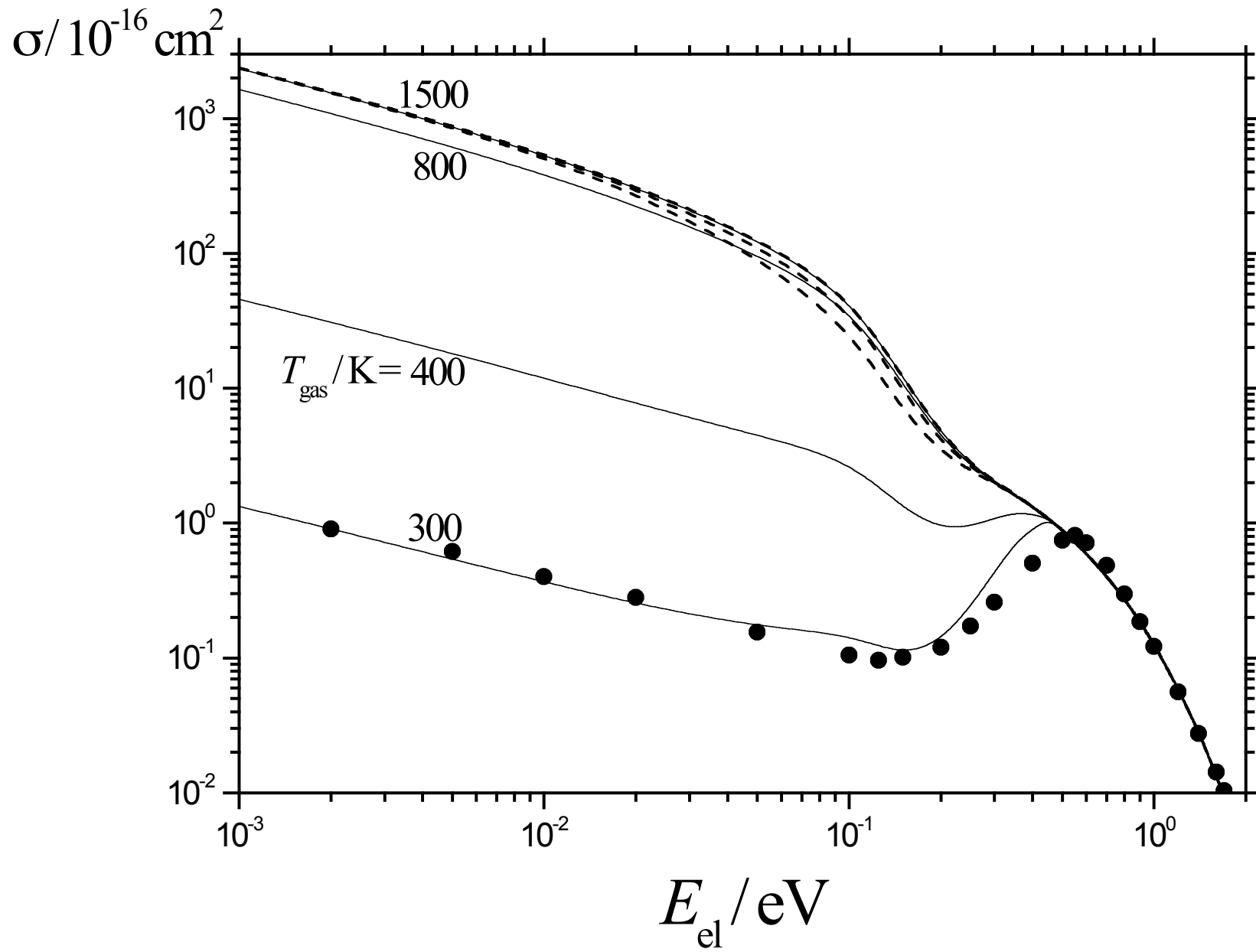












From thermal attachment and detachment rates via third law analysis to a reliable electron affinity of SF_6^- :

$$EA = 1.20 (\pm 0.05) \text{ eV}$$

From dissociative attachment yields at $E_{el}(T_{gas} = 300 \text{ K}) \rightarrow 0$ and at $T_{el} = T_{gas}$ from 300 \rightarrow 600 K to a reliable dissociation energy of SF_6^- :

$$E_0(\text{SF}_6^- \rightarrow \text{SF}_5^- + \text{F}) = 1.61 (\pm 0.05) \text{ eV}$$